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| Substitute for form 1449A/PTO   |  |  |          |           |   | L                                | Application Number  | Filed Herewith                  |                       |                                      |               |
|   |  |  |          |           |   |                                  | Filing Date   | July 16, 2003                   |                       |                                      |               |
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT   |  |  |          |           |   | 1                                | First Named Inventor:   | Aaditya Mahajan                 |                       |                                      |               |
| (use as many sheets as necessary)   |  |  |          |           |   |                                  | Examiner name: unknown  | GROUP: unknown                  |                       |                                      |               |
| Sheet   |  |  |          |           |   |                                  | Attorney Docket Number  | TRQ-12957                       |                       |                                      |               |
| U.S. PUBLISHED PATENT APPLICATIONS  |  |  |          |           |   |                                  |   |                                 |                       |                                      |               |
| Examiner  | Cited U.S. Patent Document   |  |          |           |   |                                  | Name of Patentee or Applicant of                                | Date of Publicati               |                       | Pages, Columns, Lines                |               |
| Initials*   | No. 1  | Number Kind Code <sup>2</sup> (if known)                     |          |           |   |                                  | Cited Document  | of Cited Document<br>MM-DD-YYYY |                       | Where Relevant Info.  Appear         |               |
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| Examiner<br>Initials*   | Cited<br>No. 1   | Office <sup>3</sup> Number <sup>4</sup> Kind Code (if known) |          |           |   |                                  | Name of Patentee or Applicant of Cited Document                 | Cited Document I                |                       | Relevant Info. T <sup>6</sup> Appear |               |
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